SCIENTIFIC **Reports**

Received: 28 October 2016 Accepted: 27 February 2017 Published: 31 March 2017

OPEN Shock-Resistibility of MEMS-**Based Inertial Microswitch under Reverse Directional Ultra-High g Acceleration for IoT Applications**

Qiu Xu¹, Zhuoqing Yang¹, Yunna Sun¹, Liyan Lai¹, Zhiyu Jin¹, Guifu Ding¹, Xiaolin Zhao¹, Jinyuan Yao¹ & Jing Wang²

This paper presents a novel MEMS-based inertial microswitch design with multi-directional compact constraint structures for improving the shock-resistibility. Its shock-resistibility in the reverse-sensitive direction to ultra-high g acceleration (~hunderds of thousands) is simulated and analyzed. The dynamic response process indicates that in the designed inertial microswitch the proof mass weight G, the whole system's stiffness k and the gap x_2 between the proof mass and reverse constraint blocks have significant effect on the shock-resistibility. The MEMS inertial microswitch micro-fabricated by surface micromachining has been evaluated using the drop hammer test. The maximum allowable reverse acceleration, which does not cause the spurious trigger, is defined as the reverse acceleration threshold (a_{thr}) . Test results show that a_{thr} increases with the decrease of the gap x_{2r} and the proposed microswitch tends to have a better shock-resistibility under smaller gap. The measured responses of the microswitches with and without constraint structure indicates that the device without constraint structure is prone to spurious trigger, while the designed constraint structures can effectively improve the shock-resistibility. In this paper, the method for improving the shock-resistibility and reducing the spurious trigger has been discussed.

Microelectromechanical systems (MEMS) inertial microswitches based on surface micromachining technology have attracted a great deal of attention due to their small size, lower costs and large volume production^{1,2}. They are widely used in many applications such as accessories, toys, the transportation of special goods, automotive electronics and remote monitoring (RMON)³⁻⁵. In the coming years, the rapid growth of internet of things (IoT) will lead to a growing demand of MEMS inertial switches which are used for monitoring in IoT devices. The MEMS inertial microswitch behaves as a passive device that does not consume power until an acceleration event occurs. Therefore, it can be used in some long-lifetime systems such as the internet of things in spite of the limited available power. The new chipless radio frequency identification (RFID) tag can operate at the conventional UHF band for RFID applications. In the presented scheme, MEMS inertial switches are used as programmable elements to support communication between the tag and RFID interrogators⁶⁻⁸. It can be employed to monitor the shock from the environment in order to protect the device against the damage from the overload shock in the IoT sensors.

The working principle of an inertial switch is that the movable electrode moves along the sensitive direction and comes into contact with the stationary electrode to form an electric path when it is triggered by an over-threshold acceleration in the sensitive direction. If the microswitch is subjected to a large enough acceleration in the reverse sensitive direction, large deflection of the suspension spring would occur, thus causing the proof mass (i.e., movable electrode) to rebound in the sensitive direction. A spurious trigger may happen if the rebounding distance of the proof mass reaches the gap x_1 between the proof mass and stationary electrode. In the previous reports⁹⁻¹³, several kinds of microswitches have been designed, simulated and fabricated, while the threshold acceleration, the switch-on time and the reliability are discussed when the acceleration is applied in the

¹National Key Laboratory of Science and Technology on Micro/Nano Fabrication, School of Electronic Information and Electrical Engineering, Shanghai Jiao Tong University, Shanghai, 200240, China. ²Electrical Engineering Department, University of South Florida, Tampa, FL 33620, USA. Correspondence and requests for materials should be addressed to Z.Y. (email: yzhuoqing@sjtu.edu.cn) or G.D. (email: gfding@sjtu.edu.cn)



Figure 1. The schematic diagram and structure parameters of the designed inertial microswitch. (a) The 3D view of the whole structure. (b,c) The close-ups of the switch. (d) The top view of a quarter of the switch. (e) The side view of the one-half structure.

sensitive direction. In the practical applications, the inertial microswitch will inevitably be subject to high or even ultra-high shocks along the reverse direction because of the complicated working environment. Unfortunately, very few prior works addressed the shock-resistibility issue by reducing the spurious trigger. In this regard, a novel laterally-driven inertial microswitch with multi-directional compact constraint structures is proposed and thoroughly investigated. Moreover, the effects of the proof mass weight *G*, the whole system stiffness *k* and the gap x_2 on the shock-resistibility are analyzed when the switch is subjected to an acceleration in the reverse sensitive direction (-*x* direction).

The lowest reverse acceleration, which is the onset critical value for making the switch to turn on incorrectly, is defined as the reverse acceleration threshold (a_{thr}). As a result, the circuit will not conduct current when the applied reverse acceleration is less than a_{thr} . It is a very crucial parameter for the microswitch, which represents the shock-resistibility of the designed device. The proposed inertial microswitch design will be simulated and evaluated when the reverse threshold acceleration has been applied in the simulation model. Finally, the fabricated inertial microswitch has been fully tested by a drop hammer system.

Results

Structure design. As compared to the silicon substrate, the insulated quartz substrate is less likely to be broken to pieces under the ultra-high g acceleration. When the insulated quartz substrate is heated during the fabrication process, it won't delaminate from the metal switch microstructures due to the small thermal expansion coefficient of quartz. Therefore, the novel inertial microswitchs with multi-directional compact constraint structures for improving the shock-resistibility have been designed and fabricated over an insulated quartz substrate. The microswitch mainly consists of three parts: two L-shape cantilever beams attached to the proof mass as the movable electrodes; one spring shape cantilever beam supported by anchors as the stationary electrode; and the compact constraint structures consisting of constraint layer with holes and reverse constraint blocks to limit the vibration in the reverse sensitive direction. The schematic diagram of the designed microswtich is shown in Fig. 1(a). The supply voltage source *V*, the bias resistance R_1 (300 Ω) and the sufficient switch movement in the *x* direction form an electric path when the two electrodes touch. The supply voltage source *V*, the bias resistance R_2 (300 Ω) and the sufficient switch movement in the *z* direction make another circuit when the proof mass collides with the constraint layer. In this designed inertial microswitch, the two sensitive in-plane directions of the device (*x* direction) are equivalent and they are parallel to the substrate plane. In this paper, the *x*



Figure 2. Rotation and movement process of the proof mass in moving toward stationary electrode (a) with constraint layer and (b) without constraint layer.



Figure 3. Collision response time between the proof mass and constraint structures changing with (**a**) gap (x_3) between the proof mass and constraint structures and (**b**) applied acceleration amplitude in the sensitive direction.

direction characteristics will be mainly discussed. The gap x_1 between movable electrode and stationary electrode has been set to $20 \,\mu\text{m}$ as shown in Fig. 1(b). The gap x_2 between the proof mass and reverse constraint block is depicted in Fig. 1(c). Figure 1(d,e) show the top view and the side view of the microswitch, respectively.

Physical model and theoretical analysis. The inertial microswitch with the constraint layer can be simplified to a spring-mass system with constraint structures as shown in Fig. 2(a). (i) Firstly, the proof mass will rebound toward the stationary electrode after it collides with the reverse constraint block. (ii) Considering that the centroid deviation between the proof mass and serpentine springs inevitably exists during the resilient process, the caused moment will make the proof mass rotate in clockwise direction in the xoz plane until it collides with the upper constraint layer. (iii) The proof mass will also rotate in the anticlockwise direction under the action of collision rebound. Finally, the proof mass may collide with constraint structures a few times in moving toward stationary electrode. The whole system's energy will be dissipated to some extent due to the frequent collisions between the proof mass and the top constraint structures. Therefore, the resilient distance in the sensitive direction is reduced. Correspondingly, it is more robust to the spurious trigger that is more difficult to happen. As soon as the constraint layer is broken, the inertial microswitch can be simplified and sketched in Fig. 2(b). If the inertial microswitch rebounds in the sensitive direction, there is no collision between the proof mass and constraint layer. Then, the proof mass will freely rotate in the xz plane. The whole system's energy will not be easily consumed as compared to the switch with constraint layer. Apparently, the resilient distance without the constraint layer in the sensitive direction is larger than the one with the constraint layer. The device without the constraint layer is much more prone to spurious trigger.

In this paper, the delay from time zero (zero input) to the time when the proof mass firstly starts to contact the constraint layer is defined as the collision response time (t_c) in z-axis direction. The first collision response time is related to the off-axis sensitivity of inertial microswitch. When the microswitch with constraint structures is triggered by the acceleration, the first collision response time decreases with the increases of the collision frequency



Figure 4. The dynamic response curves of movable electrode under the maximum allowable reverse acceleration threshold a_{thr} when (**a**) different proof mass weight G, (**c**) different gap x_2 between the proof mass and reverse constraint block; (**e**) different whole system stiffness k. Dependences of a_{thr} on (**b**), G (**d**) x_2 and (**f**) k.

between the proof mass and constraint layer. Correspondingly, the whole system's energy is dissipated to some extent due to the frequent collision. In order to better understand the dynamic behavior of designed inertial microswitch, an analytical method is proposed to evaluate the collision response time (t_c).

It can be seen from Fig. 2(a) that the proof mass collides with constraint layer when the proof mass rotates by a θ angle in clockwise direction of the *xz* plane. The rotation of proof mass can be expressed as follows:

$$J_z \alpha = kx \cdot d \tag{1}$$

where J_z represents the rotational inertia of system, α stands for the angular acceleration, x is the displacement of proof mass, and d represents the distance between centroid of proof mass and the plane of serpentine springs.

When the inertial microswitch is mechanically shocked by a reverse acceleration at the threshold value a_{thr} , the proof mass firstly collides with the reverse constraint block and then rebounds in the sensitive direction. In this paper, this rebound acceleration is equivalent to a sensitive acceleration *a* applied to the device. In practice, the acceleration *a* is usually a half-sine wave with the peak value a_0 and frequency w_0 . During this rebound process in the sensitive direction, the differential equation of motion can be expressed as follows:

$$m\ddot{x} + c\dot{x} + kx = ma_0 \sin w_0 t \tag{2}$$

where m is the mass of proof mass, c is the damping coefficient, k represents the whole system spring constant of four constituent serpentine springs, x is the displacement of proof mass.



Figure 5. (a) The dynamic response curves of movable electrode with constraint layer and without constraint layer under the same acceleration 45000 g in the reverse sensitive direction. (b) Stress distribution of the serpentine spring reaching the reverse maximum displacement under the reverse acceleration of 45000 g.







Figure 7. (a) Dropping shock equipment for testing the fabricated inertial microswitch; (b) The schematic diagram of test circuit; (c) The photo of the fabricated inertial microswitch.

.....

By solving the Eqs (1) and (2)¹⁴, the first collision response time (t_c) between the proof mass and constraint structures in *z*-direction can be expressed as:

$$t_c^2 \left(\sin w_0 t_c - \frac{w_0}{w_n} \sin w_n t_c \right) = \frac{\theta(L_1^2 + H^2)}{3w_n^2 a_0 d}$$
(3)

where, L_1 and H are length and height of the proof mass, respectively, ω_n is the inherent frequency of mass-spring inertial system and θ is the rotation angle, as shown in Fig. 2(a). It can be seen from Fig. 2(a) that the ration angle θ can be expressed as follows:

$$\sin \theta = \frac{2x_3}{L_1} \tag{4}$$

where x_3 is the gap between proof mass and constraint layer. According to Eq. (3), one can obtain plots of the first collision response time varied with applied acceleration amplitude and gap (x_3) between proof mass and constraint layers. It can be observed in Fig. 3(a) that the collision response time increases with the gap (x_3) between proof mass and constraint structures. Figure 3(b) shows that the collision response time decreases with the increase of the rebound acceleration *a*. The collision response time reflects the frequency at which the proof mass collides with the constraint layer. The shorter the collision response time is, the more frequently the proof mass would collide with the constraint structures. Therefore, the resilient distance in the sensing direction becomes smaller because the whole system energy is dissipated to some extent. The movement of the proof mass should be restrained and the spurious trigger should not happen easily because of the frequent collision between the proof mass and the constraint layer. As a result, the shock-resistibility of the microswitch is improved. When the constraint layer.

Methods

FEM simulation. The ANSYS software was employed to simulate the dynamic contact process. A convenient and accurate analysis can be conducted by this finite element method (FEM) software to evaluate the resistance threshold to the reverse accelerations when the proof mass rebounds in the sensitive direction. From the previous experimental results¹⁵, the main structural material of the inertial switch is electroplated nickel and its properties are as follows: Poisson's ratio is 0.3, Young's modulus is 171.5 GPa and density is $8.96 \text{ g} \cdot \text{cm}^{-3}$.

In the practical applications, the inertial microswitch will inevitably be subject to shocks from different directions. Especially in the opposite direction, the spurious trigger will happen if the resilient distance of the movable electrode is exactly equal to the gap x_1 (20 μ m) between the stationary electrode and the movable



Figure 8. Test results of the fabricated inertial switch. (a) The test switch is not triggered under the reverse acceleration 1309 g. (**b**–**f**) Test reverse acceleration threshold a_{thr} (1320 g, 846 g, 770 g, 648 g, 528 g) of the fabricated inertial microswitch with constraint layer when the gap x_2 between proof mass and reverse constraint block is 20 µm, 23 µm, 27 µm, 29 µm and 30 µm, respectively.

.....

electrode. Therefore, the dynamic response of inertial microswitch mechanically shocked in the reverse sensitive direction should be investigated. The maximum allowable reverse acceleration, which does not cause the switch spurious trigger, is defined as the reverse acceleration threshold (a_{thr}) . The acceleration a_{thr} indicates the shock-resistibility of the inertial switch and it is the significant parameter for evaluating the structure of designed inertial microswitch. For an inertial switch, the key factors affecting a_{thr} are the proof mass weight *G*, the whole system stiffness *k* and the gap x_2 between proof mass and reverse constraint block. In the following section, the three factors will be analyzed individually.

Effect of the proof mass weight G on the shock-resistibility of inertial microswitch. The proof mass weight G is one of the most important factors influencing the reverse acceleration threshold a_{tirr} . Here, the thickness t_0 of the spring and the gap x_2 are set to $10 \,\mu$ m. As a result, the whole system stiffness k and the gap x_2 are invariant. The proof mass weight G is defined as 'm' when the thickness H of proof mass is $55 \,\mu$ m, $60 \,\mu$ m, $70 \,\mu$ m and $80 \,\mu$ m, correspondingly the proof mass weight G is $0.55 \,m$, $0.6 \,m$, $0.7 \,m$ and $0.80 \,m$ due to the same in-plane geometrical structure. Figure 4(a) shows the simulated displacement-time curves of movable electrode under the maximum allowable reverse acceleration a_{thr} for different varied proof mass weight G. When the G changes from $0.55 \,m$ to m, the corresponding reverse acceleration





threshold a_{thr} is 160000 g, 150000 g, 145000 g, 130000 g and 100000 g, respectively. Here, the acceleration of 1 g is equal to 9.8 m/s². The pulse width is 1 ms. It can be seen from Fig. 4(b) that the reverse acceleration threshold a_{thr} decreases with the increase of the proof mass weight G. In other words, the microswitch tends to have better shock-resistibility under smaller G. Figure 4(a) indicates that the proof mass firstly moves in the reverse sensitive direction and collides with the reverse constraint block during the forced vibration process. Then it rebounds and the spurious trigger occurs during the free vibration process.

Effect of the gap x_2 **on the reverse acceleration threshold** a_{thr} . In addition, the gap x_2 between proof mass and reverse constraint block also has a great impact on the reverse acceleration threshold a_{thr} . Figure 4(c) shows the dynamic response curves of movable electrode under the maximum allowable reverse acceleration a_{thr} for different varied gap x_2 . Here, the thickness of the spring and the proof mass is 10 µm and 80 µm, respectively. When the gap x_2 changes from 5 µm to 22 µm (i.e. 5 µm, 10 µm, 16 µm, 18 µm, 20 µm and 22 µm), the reverse acceleration threshold a_{thr} is 170000 g, 150000 g, 90000 g, 50000 g, 2000 g and 800 g, respectively. It can be observed from Fig. 4(d) that a_{thr} decreases with the increase of the gap x_2 between the proof mass and reverse constraint block. As a consequence, the microswitch tends to have better shock-resistibility under smaller gap x_2 . For the inertial switch, reduction of the gap x_2 is an effective way to circumvent the spurious trigger and make the device more reliable.

Effect of the whole system stiffness k on the reverse acceleration threshold a_{thr} . In order to investigate the dependence of the shock-resistibility of inertial microswitch on the whole system stiffness k, the invariant gap x_2 and the proof mass weight G are set as 16 µm and 0.8 m, respectively. Figure 4(e) shows the displacement-time curves of movable electrode for different the whole system stiffness k. When the thickness t_0 of the spring changes from 4 µm to 11 µm (i.e. 4 µm, 6 µm, 7 µm, 8 µm, 10 µm and 11 µm), the corresponding whole system stiffness k is 12.21 N/m, 17.79 N/m, 19.92 N/m, 23.42 N/m, 30.41 N/m and 32.46 N/m, respectively. The reverse acceleration threshold a_{thr} is 48000 g, 70000 g, 78000 g, 82000 g, 90000 g and 96000 g, respectively. It can be seen from Fig. 4(f) that a_{thr} increases with the whole system stiffness k. As a result, the microswitch tends to have better shock-resistibility under larger stiffness k.

Effect of constraint structures on the reverse acceleration threshold a_{thr} . In the practical applications, the inertial microswitch will inevitably be subject to shocks in different directions because of the complicated working environment. Especially in the reverse sensitive direction, the possible spurious trigger will happen if the resilient distance reaches the gap x_2 between the proof mass and the reverse constrain block. Therefore, the dynamic response process of the inertial microswitch triggered by the reverse sensitive acceleration should be investigated. In this design, a constraint layer is introduced to restrain the overload impaction from the opposite direction. Figure 5(a) shows the dynamic responses curves of movable electrode with and without the constraint layer. It indicates that the resilient distance with the constrain layer is less than the gap x_2 while the resilient distance without the constraint layer is broken. Therefore, the constraint layer can improve the shock-resistibility of the inertial microswitch and eliminate the spurious trigger. When the inertial switch is mechanically shocked by the applied acceleration of 45000 g in the reverse direction, the maximum stress of the serpentine spring reaching the reverse maximum displacement is 288.63 MPa as shown in Fig. 5(b), which is smaller than the yield strength of electroplated nickel of 317 MPa.

In short, the reverse acceleration threshold a_{thr} decreases with the increase of the proof mass weight *G* and the gap x_2 , and a_{thr} increases with the whole system stiffness *k*. Besides, the constraint layer can improve the shock-resistibility and prevent the spurious trigger.



Figure 10. (a) The testing principle diagram of the contact resistance. (b) Test of the PCB with packaged MEMS inertia microswitch under the reverse acceleration for vibration monitoring systems.

.....

Device Micro-Fabrication. The designed inertial microswitch was fabricated on the quartz substrate by a multilayer lithography and electroplating process based on the surface micromachining technology. The main fabrication process steps of the inertial microswitch is illustrated in Fig. 6(a) and described as follows:

- (i) Firstly, Cr/Cu with a 300 nm total thickness was sputtered on the quartz wafer substrate. Then an array of the pads, anchors and raised strips were electroplated in nickel after the photoresist mold was patterned.
- (ii) Next, the anchors, which suspended the springs, were electroplated for x_4 higher than the anti-adhesion strips in order to form the first suspended layer.
- (iii) The spring layer was electroplated after the Cr/Cu was sputtered on the first suspended layer as the second seed layer.
- (iv) The proof mass was electroplated up to the required thickness by multiple lithography and multi-layer electroplating process technology.
- (v) The anchors were fabricated thicker than the proof mass in order to build a gap x_3 between the bottom of constraint layer and the top of proof mass.
- (vi) The constraint layer was electroplated after lithography technology.
- (vii) The photoresist and the chromium/copper seed layer were completely removed by sodium hydroxide solution and an ammonia/peroxide solution, respectively.

Figure 6(b) is the SEM micrograph of the released, completed inertial microswitch. Figure 6(c) shows the close-up image of the gap x_1 between the movable electrode and the stationary electrode, while Fig. 6(d) present close-up photo of the gap x_2 between the proof mass and the reverse constraint block.

Discussions

Experiment test. As shown in Fig. 7(a), the fabricated inertial microswitches were characterized by a drop hammer test. The drop hammer was freely dropped onto the base platform from different pre-determined height *H*. The amplitude of acceleration increases with the height *H*. The test circuit is shown in Fig. 7(b). If the inertial microswitch was shocked by the acceleration, which was larger than its threshold level, the spurious trigger signal (yellow signal), *z*-off-axis collision trigger signal (purple signal) and accelerometer signal (green signal) could be simultaneously captured by the multi-channel oscilloscope.

Effect of the gap x_2 on the test acceleration a_{thr}. The test results of the fabricated inertial microswitches with different acceleration peak values are presented in Fig. 8. When the drop hammer was dropped from a height of about 210 cm above the base platform, the fabricated inertial microswitch experienced an acceleration of 1309 g in the reverse sensitive direction (-*x* direction). It can be seen from Fig. 8(a) that there is no trigger signal observed in the sensitive +*x* direction. The height *H* and the acceleration were then increased gradually until an output impulse began to appear, as shown in Fig. 8(b). The minimum applied acceleration in the reverse direction for microswitch to result in a spurious trigger was defined as the reverse acceleration threshold a_{thr} , which was 1320 g for the inertial microswitch of sample 1, whose gap x_2 between the proof mass and reverse constraint block is 20 µm. Figure 8(b) indicates that the spurious trigger occurs after the half-sine wave acceleration, the delaying time is about 0.42 ms. The reason is that the rebound of the proof mass appears after the free vibration stage, which is in good accordance with the simulated results. When the gaps x_2 between proof mass and reverse constraint block are 23 µm, 27 µm, 29 µm and 30 µm, respectively, the test reverse acceleration threshold values are 846 g, 770 g, 648 g and 528 g, respectively, as shown in Fig. 8(c-f). Figure 9 shows that tested reverse acceleration threshold a_{thr} decreases with the increase of the gap x_2 between proof mass and reverse constraint block. It is demonstrated that the inertial microswitch tends to have better shock-resistibility under smaller gap x_2 .



Figure 11. (a) The optical photograph of the fabricated microswitch with constraint layer and test results under reverse acceleration 658 g (no spurious trigger). (b) The optical photograph of the fabricated microswitch when constrain layer is broken and test result under the same reverse acceleration 658 g (have spurious trigger).

Figure 10(a) shows the schematic for the measurement of the contact resistance in the fabricated microswitch. The divider resistance R_1 (300 Ω), the contact resistance R_x of the inertial microswitch, copper wires and constant-voltage power supply (7 V) form an test electric path when the movable electrode comes into contact with the stationary electrode under the applied acceleration. In this circuit, the divider voltage (V_m) of the divider resistance can be detected by connecting the oscilloscope to point *m*, and the voltage of divider resistance and the switch (V_n) can be detected by connecting the oscilloscope to point *n*. The contact resistance R_x of the inertial microswitch can be obtained according to the law of current conservation in the series circuit:

$$\frac{V_m}{R_1} = \frac{V_n - V_m}{R_x} \tag{5}$$

where, $V_n = 6.8$ V, $V_m = 6.6$ V and $R_1 = 300 \Omega$. The contact resistance is calculated to be 9.09 Ω by the Eq. (5).

There is a tested PCB with packaged MEMS inertial microswitch after undergoing the reverse threshold acceleration. As shown in Fig. 10(b), the LED on the PCB just turns on under the acceleration 1320 g in the reverse sensing direction. The tested reverse acceleration threshold of the MEMS inertial microswitch is 1320 g and the response time is about 0.42 ms. The PCB module with packaged MEMS inertial microswitch can be used as a shock vibration monitoring unit in the wireless sensor network node for IoT applications.

Effect of the constraint layer on the test acceleration a_{thr} . In order to investigate the function of the constraint layer, the acceleration of 658 g in the reverse sensitive direction (-*x* direction) has been applied to the fabricated inertial microswitch. Figure 11(a) shows the photo of the fabricated microswitch with constraint layer and the test result under the reverse acceleration of 658 g, which indicates that the spurious trigger in the fabricated switch with the constraint layer is prevented. The constraint layer of previous tested inertial microswitch with a broken artificially to validate the impact of the constraint layer. The photo of the fabricated microswitch with a broken constraint layer is shown in Fig. 11(b). When it was shocked by the same acceleration of 658 g in the reverse sensitive direction, the spurious trigger can be readily observed as shown in Fig. 11(b). The characterization and test results demonstrate that the constraint layer in the designed inertial microswitch can restrain the movement of the proof mass and eliminate the spurious trigger. The *z*-off-axis collision as shown in Fig. 11(a) can be observed, which indicates that the proof mass collides with the constraint layer again and again under the reverse sensitive acceleration of 658 g. The whole system energy is consumed to some extent and the resilient distance is reduced which is the reason for the spurious trigger does not happens until the reverse acceleration increases up to 849 g (a_{thr}) in the microswitch with the constraint layer. It is evident that the reverse resistant threshold acceleration



Figure 12. Spurious trigger happens until the reverse acceleration increases up to 849 g (a_{thr}) in the microswitch with constraint layer in Fig. 11(a).

 a_{thr} (658 g) of the microswitch without the constraint layer is smaller than a_{thr} (849 g) of the inertial microswitch with the constraint layer. Therefore, it is demonstrated that the constraint layer can improve the shock-resistibility.

Conclusion

A novel inertial microswitch with multi-directional compact constraint structure for improving the shock-resistibility was proposed and demonstrated. Its shock-resistibility in the reverse sensitive direction to ultra-high g acceleration (~hunderds of thounsands) was simulated. The simulation reveals that in the designed inertial microswitch the proof mass weight *G*, the whole system stiffness *k* and the gap x_2 between proof mass and reverse constraint blocks are important influential factors for the shock-resistibility in the reverse sensitive direction. The reverse acceleration threshold (a_{thr}) decreases with the increase of the proof mass weight *G* and the gap x_2 , while increasing with the whole system stiffness *k*. The inertial microswitch fabricated by surface micromachining technology has been evaluated by a standard drop hammer test. The test results show that a_{thr} increases with the decrease of the gap x_2 , and the microswitch tends to have better shock-resistibility under smaller gap. The comparison of the measruement results of the microswitches with and without the designed constraint structure indicates that the design without the constraint structure is more susceptible to spurious trigger and the designed constraint structures can effectively improve the shock-resistibility. These conclusions obtained in this work will provide some fundamental guidance for the future design and fabrication of the inertial microswitch in order to further improve shock-resistibility and circumvent the spurious trigger. And the developed passive MEMS inertial microswitch is promising to be used as a shock vibration monitoring sensor for IoT application.

References

- W. Ma, Y. Zohar & M. Wang. Design and characterization of inertial-activated electrical micro-switches fabricated and packaged using low-temperature photoresist molded metal-electroplating technology. J. Micromech. Microeng. 6, 892–899 (2003).
- 2. Z. Yang *et al.* Design, simulation and characterization of an inertia microswitch fabricated by non-silicon surface micromachining. *J. Micromech. Microeng.* **17**, 1589–1604 (2007).
- 3. Z. Yang *et al.* A MEMS inertial switch with bridge-type elastic fixed electrode for long duration contact. *IEEE Transaction on Electron.* 55, 2492–2497 (2008).
- 4. T. Matsunaga & M. Esashi. Acceleration switch with extended holding time using squeeze film effect for side airbag systems. *Sens. Actuators A.* **100,** 10–17 (2002).
- 5. L. Zimmermann *et al.* Airbag application: a microsystem including a silicon capacitive accelerometer, CMOS switched capacitor electronic and true self-test capability. *Sens. Actuators A* **3**, 190–195 (1995).
- Programmable Chipless Radio Frequency Identification Tag Using RF MEMS Switches, in press, IEEE Internet of Things Journal, doi: 10.1109/JIOT.2016.2589928 (July, 2016).
- 7. A. Attaran & R. Rashidzadeh. Ultra low actuation voltage RF MEMS switch. Micro and Nano Systems Letters 3, 1-3 (2015).
- A. Attaran, R. Rashidzadeh & R. Muscedere. Chipless RFID tag using RF MEMS switch. *Electronics Letters* 50, 1720–1722 (2014).
 W. Chen *et al.* Influence of applied acceleration loads on contact time and threshold in an inertial microswitch with flexible contact-enhanced structure. *Sens. Actuators A* 216, 7–18 (2014).
- Y. Wang *et al.* The design, simulation and fabrication of a novel horizontal sensitive inertial micro-switch with low g value based on MEMS micromachining technology. J. Micromech. Microeng. 23, 105013 (2013).
- H. Cai et al. Design, simulation and fabrication of a novel contact-enhanced MEMS inertial switch with a movable contact point. J. Micromech. Microeng. 18, 115033 (2008).
- 12. Z. Yang *et al.* Modeling, Simulation and Characterization of a Micromachined Acceleration Switch with Anti-Stiction Raised Strips on the Substrate. *IEEE Transactions on Components, Packaging and Manufacturing* **1**, 1195–1204 (2011).
- 13. Q. Xu *et al.* A surface-micromachining-based inertial micro-switch with compliant cantilever beam as movable electrode for enduring high shock and prolonging contact time. *Applied Surface Science* **387**, 569–580 (2016).
- Q. Zhang *et al.* Design and fabrication of a laterally-driven inertial microswitch with multi-direction constraint structures for lowering off-axis sensitivity. J. Microench. Microeng 26, 055008 (2016).
- 15. J. Tang *et al.* A directly strain measuring method for electroplated nickel micro-tensile test. J. Microsyst. Technol. 16, 1839–1844 (2010).

Acknowledgements

The authors would like to thank the support from the Hi-Tech Research and Development Program of China (2015AA042701) and the National Key Laboratory of Micro/Nano Fabrication Technology Foundation (9140C790403150C79332). The Advanced Research Ministry of Education Joint Foundation (6141A02033403) and SJTU SMC Young Scholar Program (16X100080044).

Author Contributions

Qiu Xu, and Yunna Sun conceived the experiments. Qiu Xu, Liyan Lai and Zhiyu Jin carried out the device fabrication. Zhuoqing Yang, Guifu Ding and Xiaolin Zhao implemented measurements and analysis. Jinyuan Yao and Jing Wang designed the PCB module and done the application testing, Qiu Xu, Jing Wang and Zhuoqing Yang wrote the manuscript and prepared figures. All authors discussed the results and contributed to writing of the manuscript.

Additional Information

Competing Interests: The authors declare no competing financial interests.

How to cite this article: Xu, Q. et al. Shock-Resistibility of MEMS-Based Inertial Microswitch under Reverse Directional Ultra-High g Acceleration for IoT Applications. Sci. Rep. 7, 45512; doi: 10.1038/srep45512 (2017).

Publisher's note: Springer Nature remains neutral with regard to jurisdictional claims in published maps and institutional affiliations.

This work is licensed under a Creative Commons Attribution 4.0 International License. The images or other third party material in this article are included in the article's Creative Commons license, unless indicated otherwise in the credit line; if the material is not included under the Creative Commons license, users will need to obtain permission from the license holder to reproduce the material. To view a copy of this license, visit http://creativecommons.org/licenses/by/4.0/

© The Author(s) 2017